



# PRODUCTION QUALITY WAFER PROCESSING **EQUIPMENT**

LEARN MORE!



## Standard Process Modules

Configurations are available to accomodate very small to very large substrates

# **PRODUCT** The Cee® suite of wafer **OFFERINGS**

processing equipment is a complete system for developing production quality processes in R&D, laboratory, or lowvolume production environments.

### **BAKE**

Cee® Apogee® bake plates offer robust process control, exceptional reliability, and unrivaled thermal uniformity and accuracy, edge-to-edge and wafer-to-wafer.



#### **SPIN COAT**

Cee® Apogee® spin coaters feature high spin speed resolution, providing consistent, reliable results the first time, every time.



#### **DEVELOP/CLEAN**

Cee® Apogee® spin developers deliver desired performance and control resulting in repeatable, complete, spin developing process after process.











\*standard products are also available in flange mount configuration